

Remarks

Claims 1, 4 and 6 are amended.

Claims 2, 3 and 5 are original.

Claims 7-12 are new.

The application now contains claims 1-12.

Claim 1 is amended for clarity by deleting the parenthetical phrase "(reactive or unreactive)" from the end of the description of component (B) and placing the phrase "reactive or unreactive" just prior to each of the terms "oligomer" and "polymer". Support is inherent in the claim.

Claims 4 and 6 are amended to remove multiple dependencies.

Claim 4 is also reworded for clarity by deleting the phrase "using the photosensitive resin composition according to any one of claims 1 to 3" and adding the phrase "according to claim 1" to the description of step (1); by replacing the parenthetical phrase "(coating of the substrate)" with the phrase 'to generate a coated substrate' and to delete "of" from step 4. Support is inherent in the claim.

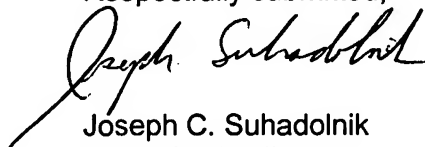
Claims 7-10 are added to reclaim material deleted by the amendments to claim 4.

Claims 11 and 12 are added to reclaim material deleted from claim 6.

No new matter is added.

Consideration of the present claims on their merits is respectfully awaited.

Respectfully submitted,



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